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APPLICATION NO.	1	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/730,672		12/06/2000	Jeffrey J. Brown	FIS9-2000-0099US1	8794
32074	7590	03/18/2003			
		BUSINESS MAC	EXAMINER		
DEPT. 18C BLDG. 300			AHMED, SHAMIM		
2070 ROU	TE 52		ART UNIT	PAPER NUMBER	
HOPEWEL	L JUNCI	TION, NY 12533		1765	7
				DATE MAILED: 03/18/2003	•

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)	
·		09/730,672	BROWN ET AL.	
Offi	ice Action Summary	Examiner	Art Unit	
_		Shamim Ahmed	1765	
The M Period for Reply	AILING DATE of this communication	appears on the cover sheet w	ith the correspondence addre	ss
• •	ED STATUTORY PERIOD FOR RE	DIVIQUET TO EYDIDE 2 M	ONTH(S) EDOM	
THE MAILING  - Extensions of tir after SIX (6) MC  - If the period for - If NO period for - Failure to reply v - Any reply receiv	B DATE OF THIS COMMUNICATION me may be available under the provisions of 37 CFI NTHS from the mailing date of this communication reply specified above is less than thirty (30) days, a reply is specified above, the maximum statutory pewithin the set or extended period for reply will, by sted by the Office later than three months after the morm adjustment. See 37 CFR 1.704(b).	N. R 1.136(a). In no event, however, may a r . In reply within the statutory minimum of thin riod will apply and will expire SIX (6) MON catute, cause the application to become AB	reply be timely filed  ty (30) days will be considered timely.  ITHS from the mailing date of this commons  BANDONED (35 U.S.C. § 133).	unication.
Status				
1)⊠ Respo	onsive to communication(s) filed on	<u>15 January 2003</u> .		
2a)⊠ This a	ction is <b>FINAL</b> . 2b)	This action is non-final.		
closed	this application is in condition for all I in accordance with the practice und			erits is
Disposition of C				
•	s) <u>1-7</u> is/are pending in the applicati			
	he above claim(s) is/are with	drawn from consideration.		
<u></u>	s) is/are allowed.			
/.	s) <u>1-7</u> is/are rejected.			
<u> </u>	s) is/are objected to.			
8)∐ Claim(s Application Pap	s) are subject to restriction ar	nd/or election requirement.		
	cification is objected to by the Exam	niner		
,— ,	wing(s) filed on is/are: a) ☐ a		he Examiner	
<i>,</i> —	ant may not request that any objection t			
* *	posed drawing correction filed on			
	oved, corrected drawings are required in		,,	
	or declaration is objected to by the			
Priority under 3	5 U.S.C. §§ 119 and 120			
13) Acknov	vledgment is made of a claim for for	eign priority under 35 U.S.C.	§ 119(a)-(d) or (f).	
a)∏ All b	o) ☐ Some * c) ☐ None of:			
1. 🔲 (	Certified copies of the priority docum	ents have been received.		
<u> </u>	Certified copies of the priority docum		pplication No	
	Copies of the certified copies of the paper application from the International attached detailed Office action for a	Bureau (PCT Rule 17.2(a)).		ge
	edgment is made of a claim for dom	•		plication).
<u> </u>	e translation of the foreign language			,
	edgment is made of a claim for dom			
Attachment(s)				
2) D Notice of Drafts	rences Cited (PTO-892) sperson's Patent Drawing Review (PTO-948) colosure Statement(s) (PTO-1449) Paper No	) 5) Notice of	Summary (PTO-413) Paper No(s). Informal Patent Application (PTO-15	
Patent and Trademark Off	ice			

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#### **DETAILED ACTION**

#### Response to Amendment

1. The amendment filed on 1/15/03 is sufficient to overcome the claims rejection under 35 USC 112, second paragraph. Accordingly, the rejection to claims 1-7 under 35 USC 112, second paragraph has been withdrawn.

Claims 1-7 are still rejected as follows.

### Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 4. Claims 1-7 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nallan et al (6,399,507).

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Nallan et al disclose a plasma etching process, wherein controlling both the capacitive plasma and the inductive plasma produces stable plasma. Nallan et al also disclose that desired power is established to light both the capacitive and the inductive plasma (col.2, lines 50-col.3, lines 4).

Nallan et al teach that the power level is established with the help of a matching network for generating and sustaining a high-density plasma (col.7, lines 32-35).

As to claim 3, Nallan et al teach that the plasma processing apparatus includes a coil for delivering power to the plasma and a current is produced in the coil due to the desired power supplied to the coil (col.9, lines 35-42 and figure 2).

As to claim 5, the gas pressure is 2 mTorr during the inductive plasma generation (col.10, lines 6-10).

As to claim 7, Nallan et al teach that the power level is greater than 20 watts (see figure 5).

Nallan et al teach that the capacitive or inductive current produced by the power source or the coil is a function of the amount of power applied for plasma generation (col.9, lines 39-42).

Nallan et al do not explicitly teach that the presetting condition of a matching network is determined to light a plasma.

However, it would have been obvious to one skilled in the art at the time of claimed invention to determine a presetting condition of a matching net work in order to tune the net work for effectively lighting a plasma as taught by Nallan et al.

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# Response to Arguments

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5. Applicant's arguments filed 1/15/03 have been fully considered but they are not persuasive.

Applicants argue that Nallan et al's teachings directed to a plasma that is already lit, as opposed to determining conditions for lighting the plasma.

This is not persuasive because Nallan et al teaches a process, wherein both the capacitive and inductive plasma are formed or lighted by controlling the process parameter with the help of a matching network (see the rejection).

Therefore, Nallan et al's teaching is directed to a process of igniting or lighting a plasma with the help of the matching network that would determined a precondition to ignite or light a plasma.

Applicants also argue that from Nallan et al's teachings, one skilled in the art would not be motivated to preset optimum conditions for lighting the plasma.

In response, examiner state that despite the silence of determining a preset condition, Nallan et al teach that the plasma is lighted or ignited with the help of a matching network for generating and sustaining a high density plasma (col.7, lines 32-34).

So, it would have been obvious to one skilled in the art would have found it desirable to determine and preset optimum conditions for lighting the plasma because the matching network is nothing but a controller for controlling and maintaining a desired power for generating and sustaining the plasma as taught by Nallan et al and also agreed upon by the applicants.

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#### Conclusion

6. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shamim Ahmed whose telephone number is (703) 305-1929. The examiner can normally be reached on M-Thu (7:00-5:30) Every Friday Off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Benjamin Utech can be reached on (703) 308-3836. The fax phone numbers for the organization where this application or proceeding is assigned are (703)-872-9310 for regular communications and (703) 872-9311 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0661.

Shamim Ahmed Examiner Art Unit 1765

SA March 13, 2003

> BENJAMIN L. UTECH SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 1700